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**Angle Robust Reflection/Transmission Plasmonic Filters Using Ultrathin Metal Patch Array**

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Color filter, as a common optical element, can be generally grouped in two categories in the light of the filtering mechanism: chemical color filter and optical color filter. Traditional chemical color filters realize the color filtering feature through the wavelength-selective absorption of the specific functional groups of the pigments and dyes, which are not stable to a variety of processing chemicals,

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cannot suffer long-time strong illumination, and will cause a significant environmental burden simultaneously. On the other hand, the optical thin film filters by multi-layer interference performs well with a high peak transmittance, a tailored bandwidth, and stable specifications. Though some researches have been carried out to lower the angular dependence of the thin film filters with metal-dielectric-metal or similar structures,<sup>[1-3]</sup> the transmission/reflection spectra move inevitably with the incidence angle. Plasmonic filters, recently as a research hotspot of the optical filters, have attracted a wide range of interests both in academic and industrial communities for the unique and extraordinary optical properties as well as the extensive potential applications in the fields of display, detecting, printing, decoration and so forth.<sup>[4-23]</sup> In recent decades, plasmonic filters with various specific nanostructures have been investigated broadly and developed in different aspects, mostly based on the surface plasmon resonance within the metallic nanostructures. However, almost all the plasmonic filters presented previously were quite sensitive to the angle of incidence, which severely limits numerous applications under large angle of oblique incidence. Though Yi-Kuei Ryan Wu proposed a novel scheme to achieve angle insensitive color filtering through the localized resonance in metallic nanoslits by light funneling, only TM polarization of the incident light was considered

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because of its intrinsic one-dimensional grating structure and cone of the incident light characterized by the azimuthal angle was also neglected, both of which limit its further application in many fields.<sup>[21]</sup> This year, Luc Duempelmann presented a plasmonic color filter based on periodic subwavelength silver nanowires, capable of changing the output color by simple rotation of a polarizer, and lower angular dependence can be observed in this scheme.<sup>[22]</sup> But this plasmonic filter has a low transmission and the angle insensitivity for p and s polarizations could be further improved. And in our previous work,<sup>[23]</sup> an omnidirectional reflective color filter based on metal-dielectric-metal (MDM) subwavelength grating structure was proposed, which can offer a high incident angular tolerance with the reflection dip wavelength invariable up to 60°. Nevertheless, the bandwidth of the filter changes gradually with the increasing incidence angle, which limits the potential applications in fields of sensing, detecting and spectral analysis. Besides, the diffusion between the ultrathin metallic layer and the dielectric film is also a big challenge for a longtime stability.

Here, a new omnidirectional plasmonic filter based on ultrathin metal patch array structure is proposed, which can present the same perceived reflection/transmission color at unpolarized

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illumination for a broad range of incident angles. The reflection/transmission curves are coincident at different angles and the color difference characterized by CIE DE 2000 is inconceivably small, implying that no color variation can be observed for a large angle up to 60 degree. The plasmonic filter can cover the whole visible wavelength range by simply adjusting the dimension of the patch structure, which is of great benefit for the realization of the complex colorful pattern with convenient manufacturing process. The localized surface plasmonic resonance excited in the single metallic patch is responsible for the angle insensitive color filtering feature of this plasmonic filter. And because of this, patch array with as few as two periods were sufficient to demonstrate color filtering.

**Figure 1(a)** shows the schematic geometry of the angle robust reflection/transmission plasmonic filter, which is comprised by a single layer of ultrathin metal patch array structure. It is noted that such simple structure of ultrathin metal patch array has been used to realize coding metasurfaces to control the reflections and scattering of electromagnetic waves.<sup>[24]</sup> Here, nanocuboid is chosen as the patch pattern in our study, and the patch pattern is not important due to the physical origin of its angle insensitive color filtering, which will be discussed in the later section of this paper. The

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thickness of the patch is denoted by  $t$ , the patch size of the nanocuboid is denoted by  $a$ , and the inter-patch distance between the adjacent nanocuboids is represented by  $d$ . The duty ratio of the patch is defined as  $f = a / (a+d)$ . The materials of incident medium and substrate are air and silica, whose refractive indices are  $n_0 = 1.0$  and  $n_s = 1.52$  respectively. Silver (Ag) is selected as the material of the patch, whose refractive index and extinction coefficient comes from the data in the book<sup>[25]</sup> (the data between the nodes derived from linear interpolation). A linearly polarized light is launched at an incident angle  $\theta$  and an azimuthal angle  $\phi$  towards the front side of the color filter. With the patch thickness to be 20 nm and the duty ratio to be 50%, reflective red, green and blue (RGB) colors can be achieved at the period of 70nm, 140nm and 240nm, respectively. Correspondingly, the transmissive colors are cyan, magenta and yellow (CMY). The geometry is designed with the help of particle swarm optimization and appropriate merit functions.<sup>[23,26-27]</sup> A commercial software FDTD Solutions, which is based on Finite-Difference Time-Domain (FDTD) method,<sup>[28-30]</sup> is adopted in our study to calculate the reflectance/transmittance of the filters as well as the electric field distribution of the structure. And the devices are fabricated by steps of sputtering deposition and focus ion beam (FIB) milling. The photos and SEM images of devices corresponding to RGB/CMY colors are displayed

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in Figure 1(b)-1(d). However, due to fabrication imperfection, the corners of the nanocuboids are rounded. Therefore, according to the FIB results shown in Figure 1(d), the practical structural parameters can be read out for different colors and the simulated results of the nanodisk pattern with parameters is calculated as well, shown in Figure 1(b) and 1(c). Obviously, the measured results agree well with the simulated results and the peak reflectance can reach 30% or more for reflective RGB filters, providing enough luminance in applications. On the other hand, the simulated transmittance of 80% or more for the high transmission region can be observed, which not only enhances luminance but also improves saturation. The difference of the simulated and measured transmittance for the high transmission region can be observed, which can be attributed to the oxidation of the material Ag. The transmittance of the micro-area device is measured by the self-made conjugate optical measurement system while the reflectance is measured by a spectrophotometer (OLYMPUS USPM-RU). As well, the absorption of these color devices are calculated and shown in the inset of Figure 1(a). Distinguished from the little absorption for the uniform Ag film of 20nm, the proposed devices present distinct absorption peaks for different colors

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responding to these reflection peaks and transmission dips, which could be attributed to the localized surface plasmon resonance excited within the structure.

With such simple structure of ultrathin metal patch array, the plasmonic filters can present good angle insensitivity feature. **Figure 2** shows the transmittance of the CMY color filters at different incidence angles for average polarization. For cyan and magenta filters, the simulated results of the nanocuboid pattern in Figure 2(a) and 2(b) indicate that the transmission spectrum almost remains the same for different incidence angles. When the size of the patch pattern increases to construct the cyan filter, the angle insensitivity property deteriorates gradually. But the cyan filter has a relatively high angular tolerance compared with those reported plasmonic filters. The simulated transmittances of the nanodisk pattern shown in Figure 2(c) matches roughly with the measured transmittances shown in Figure 2(d) and the difference of the transmittance values could be attributed to the deviation between the fabricated pattern and simulated pattern of ideal nanodisk pattern. Based on the transmission spectra, the transmitted colors are calculated by colorimetry theory as marked in a CIE 1931 chromatic diagram in supporting information. These filters can have the identical color appearance at different angles. The color difference characterized

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by CIE DE2000 formula<sup>[31-33]</sup> of these filters is limited within 2 up to 30° or more (The calculated CIE DE 2000 values of these optimized filters can be seen in supporting information), which is incredible for the so-far reported color filters. In comparison with the previous MDM filter,<sup>[23]</sup> the filter here presents better angle insensitivity with the invariable bandwidth and less color difference. Because of the increased dimension, the color difference of the cyan filter deteriorates sharply, which can be suppressed through the smaller patch size by decreasing the thickness of the patch. It should be noted that the angular performance of the patch array structure with pattern of nanocuboid is much better than that of the patch array structure with nanodisks, which can be verified in supporting information.

To reveal the physical origin of the spectral filtering feature of the proposed omnidirectional color filter, we investigated the patch array with a lateral size of 70 nm and a thickness of 20 nm at different inter-patch distances (70 nm, 400 nm and 800 nm). **Figure 3(a)** shows the reflectance curves with different inter-patch distances while the magnified reflectance curve with  $d=800\text{nm}$  is shown in Figure 3(c). It is not difficult to find that the reflection peaks are located closely (@545nm, @565nm, @569nm) for the cases of three inter-patch distances, which means that the distances

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between the patches has almost no impact on the resonance wavelength but the intensity of the peak reflection. Since various colors can be produced by different periods, it is the size of the patch pattern that determines the center wavelength. It is noted that the optically-thick metal films with perforated nanostructures can present extraordinary optical transmission (EOT) and behave as the transmissive RGB filters, attributed to the excitation of surface plasmon polaritons (SPPs). For our proposed structure, the principle of the enhanced transmission, the modulated reflection as well as the particular absorption is totally different. Figure 3(b) shows the electric field profile of the patch array structure with inter-patch distance  $d=70\text{nm}$  for peak reflectance wavelength  $\lambda=545\text{nm}$  while Figure 3(d) shows the electric field of the patch array structure with inter-patch distance  $d=800\text{nm}$  for peak reflectance wavelength  $\lambda=569\text{nm}$ . It is apparent that dipole-like resonances are excited within the patch structure for two structures with different inter-patch distances. For the patch array structure with the inter-patch distance  $d=800\text{nm}$ , which is far more than the original inter-patch distance, the filtering feature of this case resulted from the effect of the single metallic nano-patch. As a matter of fact, the single metallic patch with such small thickness and tiny size can only support localized surface plasmon resonance.<sup>[34-35]</sup> When the inter-patch distance decreases to

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70nm, the full width half maximum (FWHM) grow broad compared with that for large inter-patch distance, which implies that a weak coupling between the patches is excited in the structure with the inter-patch distance  $d=70\text{nm}$  or so, as shown in Figure 3(b). On the other hand, the localized surface plasmon resonance is excited by the specific nanostructures of the surface with the appropriate polarization and frequency of the incident light and the resonance frequency is determined by the shape and dimension of the nanostructures, which is independent with the incident wave vector (i.e. the incidence angle). Therefore, the localized surface plasmon resonance excited by the structure accounts for the angle robust spectral filtering of this reflection/transmission plasmonic filter.

Based on the analysis of the physic origin for the angle insensitive color filtering, we further study the smallest pixel to realize the color filtering sufficiently. **Figure 4** shows the SEM images and corresponding photo images with  $2 \times 2$  array,  $4 \times 4$  array,  $6 \times 6$  array,  $8 \times 8$  array for the transmissive yellow/reflective blue filter. The transmissive yellow/ reflective blue colors are kept with the periods of the pixel decreased down to 2 periods. The color seems vague when the pixel constituted by  $2 \times 2$  array, and it is because the pixel dimension ( $\sim 200\text{nm}$ ) is approaching or less than the resolution of

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the digital imaging microscope (Nikon 80i), which is restricted by the Abbe's formula.<sup>[36]</sup> And limited to the fabrication errors in our experiment, the color appearance seems not uniform due to the lack of the size uniformity of the fabricated patterns. As mentioned above, the spectral filtering feature of the ultrathin metal patch array structure resulted from the localized surface plasmon resonance excited by single metallic patch. Therefore, the fact that the patch array with as few as two periods were sufficient to demonstrate color filtering is predictable. So, the great color pattern produced by the plasmonic structural color proposed in this paper can have a high resolution approaching the diffraction limit.

In conclusion, angle insensitive plasmonic filters using ultrathin metal patch array structure are proposed. The plasmonic filters can be used as reflective RGB filters as well as transmissive CMY filters simultaneously and can present the same perceived reflection/transmission color at unpolarized illumination for a broad range of incident angles. The reflection/transmission curves are coincident at different angles and the color difference between different angles is pretty small. Various colors can be obtained by simply tuning the dimension of the patch structure. It is the localized surface plasmon resonance excited within the single metallic nano-patch that bring out the

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angle insensitive color filtering feature of this plasmonic filter. Moreover, patch arrays with as few as two periods are sufficient to demonstrate color filtering. As a matter of fact, nanoimprint technique as well as the column fabrication method based on the porous anodic alumina (PAA) template and atomic layer deposition technique are expected for the preparation of this plasmonic filter with greatly reduced fabrication time and cost, taking the place of FIB milling technique. This method, described in this paper, can have tremendous potential for various applications in the fields of display, detecting, printing, decoration and so forth.

### **Experimental Section**

#### *Simulation*

Simulation of the reflectance and the angle resolved transmittance of the plasmonic filter was performed by Finite-Difference Time-Domain (FDTD) method. In our simulation, the complex refractive index of the Ag material was obtained from the book published by CRC press.<sup>[25]</sup> The electric field distribution profile of the structure was calculated by a commercial electromagnetic field calculation software, FDTD Solutions from Lumerical Inc.

#### *Device fabrication*

The proposed angle robust plasmonic filter was manufactured on the clean substrates of fused silica.

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The ultrathin Ag film was deposited by magnetron sputtering with the base vacuum pressure better than  $5 \times 10^{-4}$  Pa. During the deposition, the substrates were kept room temperature with the sputtering power set 40W. After deposition, the pattern of the Ag film were processed by focused ion beam (FIB) milling using Carl Zeiss AURIGA Cross Beam (FIB-SEM) Workstation with the ion beam current 1.5 pA.

#### *Optical characterization*

The reflectance measurement of the fabricated device at normal incidence was performed by the spectrophotometer (OLYMPUS USPM-RU), which was equipped with an optical microscopy. The angle resolved transmittance was measured by the self-made angle resolved measurement system.

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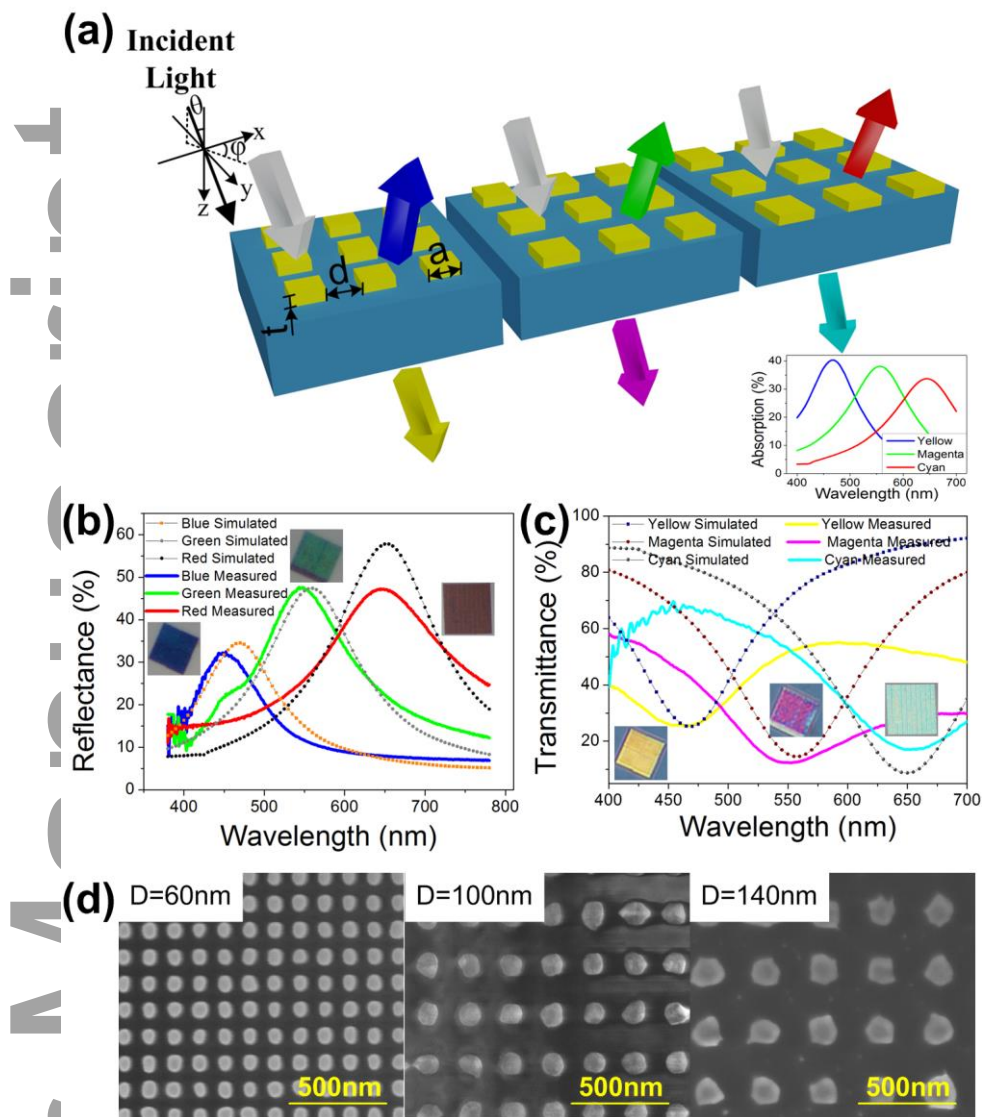
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**Figure 1** (a) The schematic geometry of the angle robust reflection/transmission plasmonic filters using ultrathin metal patch array structure. The calculated absorption of the proposed filters is shown in the inset. (b) The simulated and measured reflectance curves of the reflective RGB filters of

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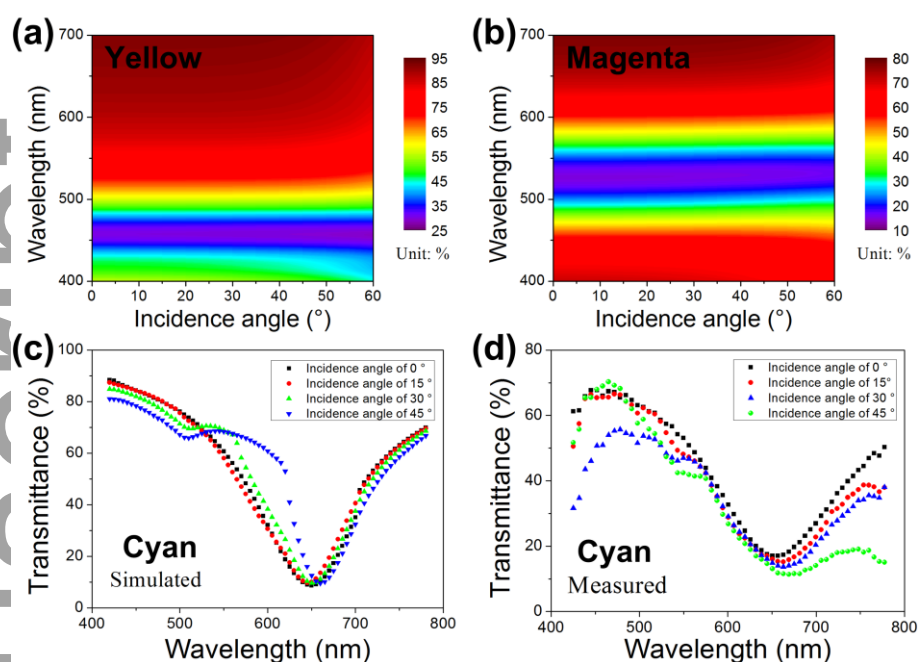
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nanodisks pattern at normal incidence with their corresponding photo images. (c) The simulated and measured transmittance curves of the transmissive CMY filters of nanodisk pattern at normal incidence and their corresponding photo images. (d) The top view SEM images of the reflective RGB / transmissive CMY filters with specific patch sizes.

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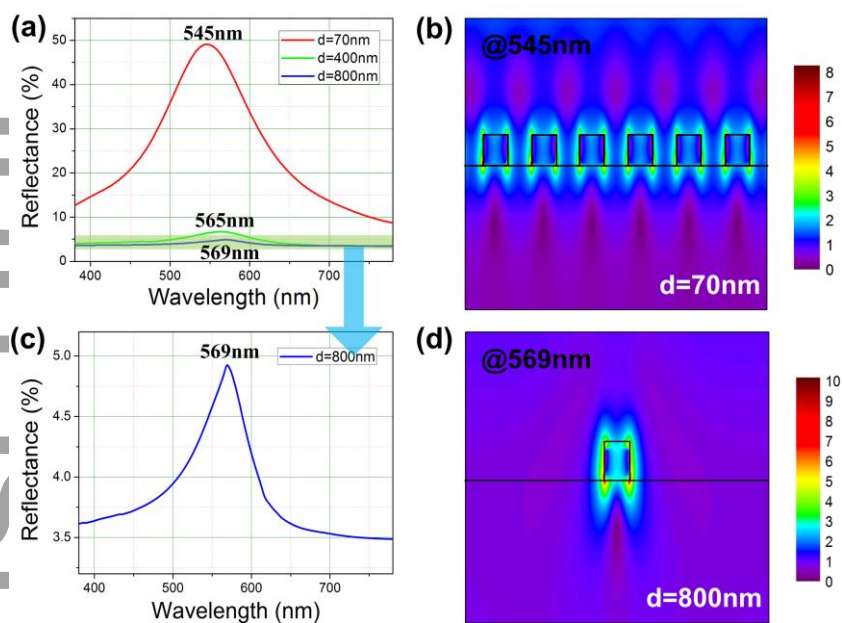
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**Figure 2** (a) Simulated transmittance of the transmissive yellow filter of the nanocuboid pattern as a function of wavelength and the angle of incidence for average polarization. (b) Simulated transmittance of the transmissive magenta filter of the nanocuboid pattern as a function of wavelength and the angle of incidence for average polarization. (c) Simulated transmittance curves of the transmissive cyan filter of the nanodisk pattern at different incidence angles for average polarization. (d) Measured transmittance curves of the transmissive cyan filter at different incidence angles for average polarization.

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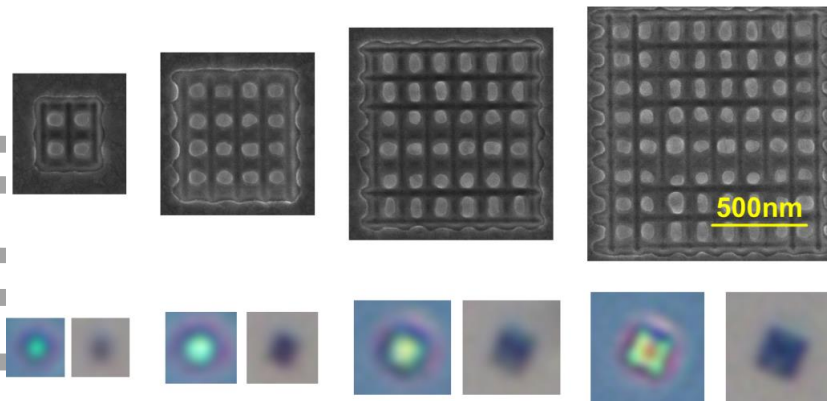
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**Figure 3** (a) The reflectance curves of the structure for the reflective green filter with three different inter-patch distances  $d=70\text{nm}$ ,  $400\text{nm}$ ,  $800\text{nm}$ . (b) The electric field distribution of the patch array structure with the inter-patch distance  $d=70\text{nm}$  for the peak reflectance wavelength  $\lambda=545\text{nm}$ . (c) The magnified reflectance curve of the patch array structure with the inter-patch distance  $d=800\text{nm}$ . (d) The electric field distribution of the patch array structure with the inter-patch distance  $d=800\text{nm}$  for the peak reflectance wavelength  $\lambda=569\text{nm}$ .

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**Figure 4** The SEM images with different pixel size and their corresponding photo images taken by digital imaging microscopy. The pixel size from left to right: 2×2 array, 4×4 array, 6×6 array, 8×8 array. The photo images of each group were taken in transmission and reflection respectively, from left to right.

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**Angle Robust Reflection/Transmission Plasmonic Filters Using Ultrathin Metal Patch Array** are proposed to achieve the angle insensitive color filtering for a broad range of incidence angles up to 60° at the unpolarized illuminations, which is attributed to the localized surface plasmonic resonance of each metal patch. Further, an array with as few as two periods are sufficient to demonstrate the color filtering effect. The reflection/transmission color determined by the resonance frequency can be tuned through adjustment of the patch size. The plasmonic filters with high angular tolerance, can have potential applications in display, colorful decoration, anti-counterfeiting and so forth.

**Keyword:** plasmonic filter, ultrathin metal patch array, angle robust, localized surface plasmon resonance

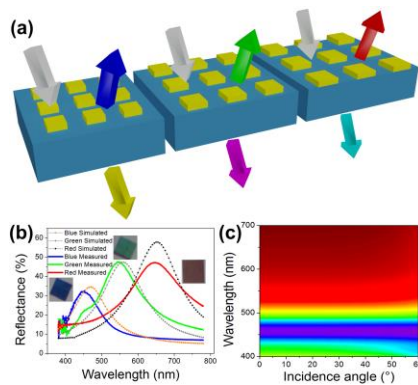
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Supporting Information

**Angle Robust Reflection/Transmission Plasmonic Filters Using Ultrathin Metal Patch Array**

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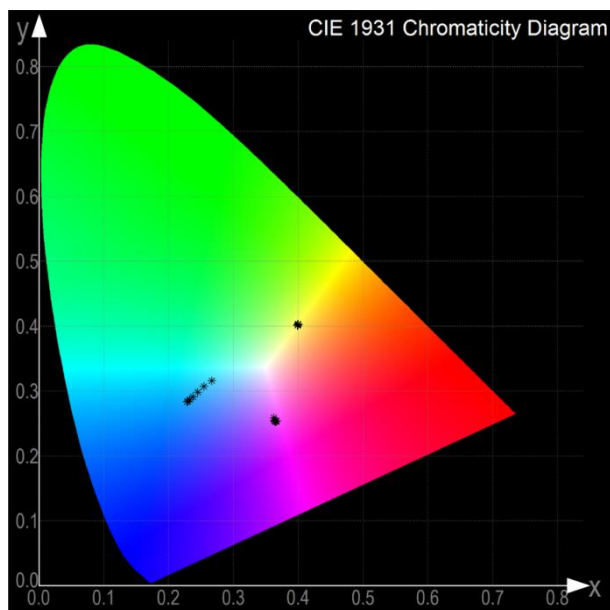


Figure S1 The CIE 1931 chromaticity coordinates of three transmissive primary color filters composed of ultrathin metallic nanocuboid array for the unpolarized light at the incidence angles of  $0^\circ$ ,  $10^\circ$ ,  $20^\circ$ ,  $30^\circ$ ,  $40^\circ$ ,  $50^\circ$ ,  $60^\circ$ .

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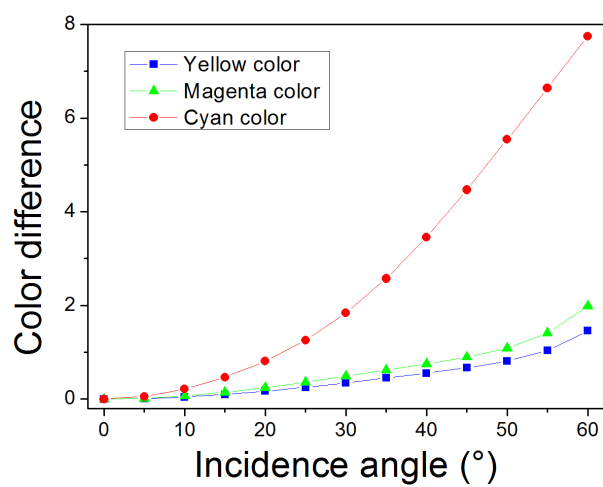


Figure S2 The color difference calculated by CIE DE2000 formula at different incidence angles compared with the normal incidence.

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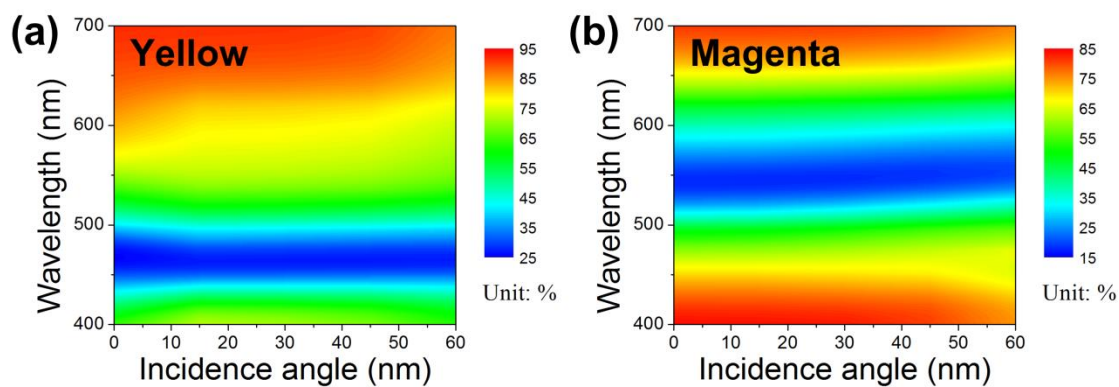


Figure S3 The angle resolved transmittance spectra of the proposed plasmonic filters with nanodisk pattern.

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